

Electronic Acknowledgement Receipt

EFS ID:	1336229
Application Number:	10720409
International Application Number:	
Confirmation Number:	5057
Title of Invention:	CMP polishing heads retaining ring groove design for microscratch reduction
First Named Inventor/Applicant Name:	Feng Chen
Customer Number:	30402
Filer:	William John Stoffel
Filer Authorized By:	
Attorney Docket Number:	CS 03-039
Receipt Date:	27-NOV-2006
Filing Date:	24-NOV-2003
Time Stamp:	21:03:04
Application Type:	Utility

Payment information:

Submitted with Payment	no
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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
1		cs03-039-roa-final-dated-2006-09-25-pt0-efs.pdf	293376	yes	28

Multipart Description/PDF files in .zip description			
Document Description	Start	End	
Amendment After Final	1	2	
Claims	3	9	
Applicant Arguments/Remarks Made in an Amendment	10	28	

Warnings:

Information:

Total Files Size (in bytes):	293376
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New Applications Under 35 U.S.C. 111
If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371
If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.